
Laser Processes for Micro and Nano Scale Functionalisation of Surfaces

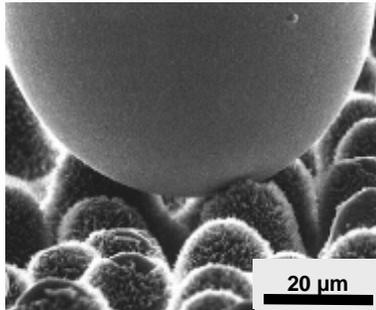
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Sebastian Theiß, Fritz Klaiber, Arnold Gillner

Hannover, 21.04.2010

Outline

- Functional structures – examples from nature
- Ultra short laser pulse interaction with metals
- Laser micro structuring
- Laser nano structuring
- New developments

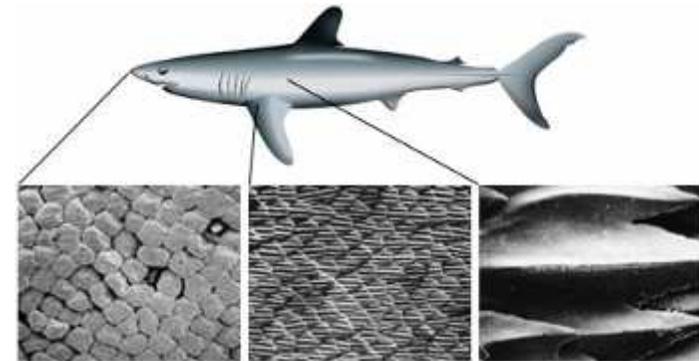
Functional structures in nature



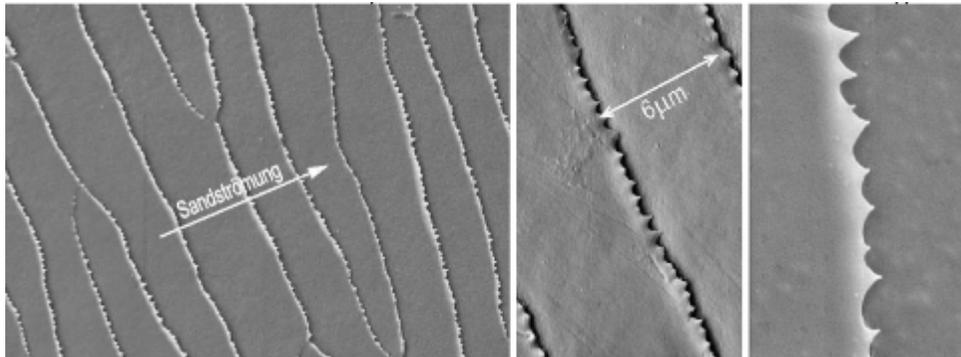
Lotus effect
Self cleaning,
water repellent



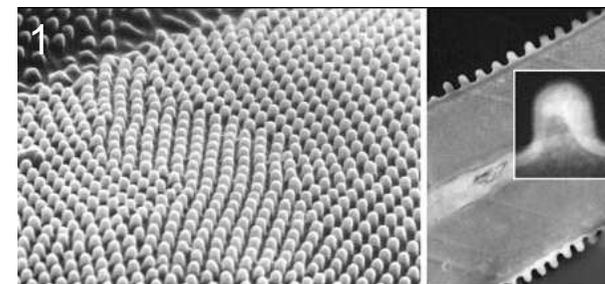
Gecko, self adhesive



Shark, low friction in fluidics



Sand fish, low friction with particles



Moth eye

Moth wing

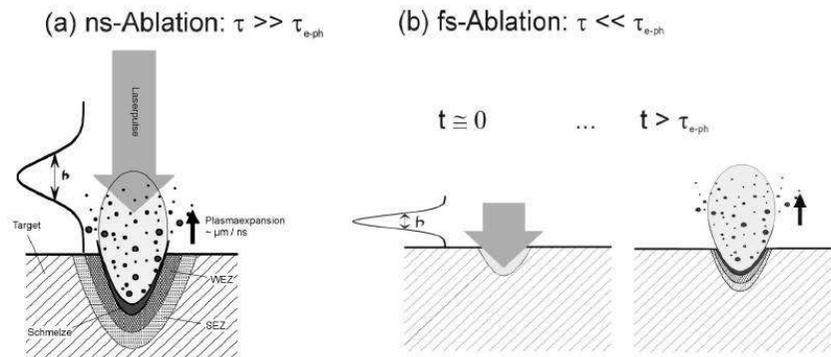
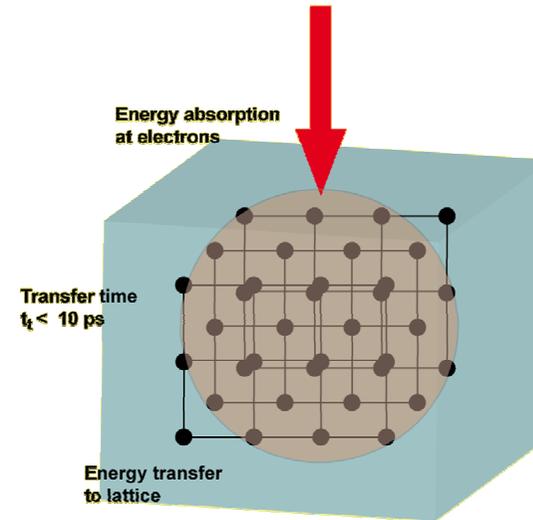
Moth eye, anti reflective

Ultra short laser pulse interaction with metals

- Energy absorption at electrons
- Transfer of energy to lattice within typical 10 ps
- Heating and melting after end of laser pulse



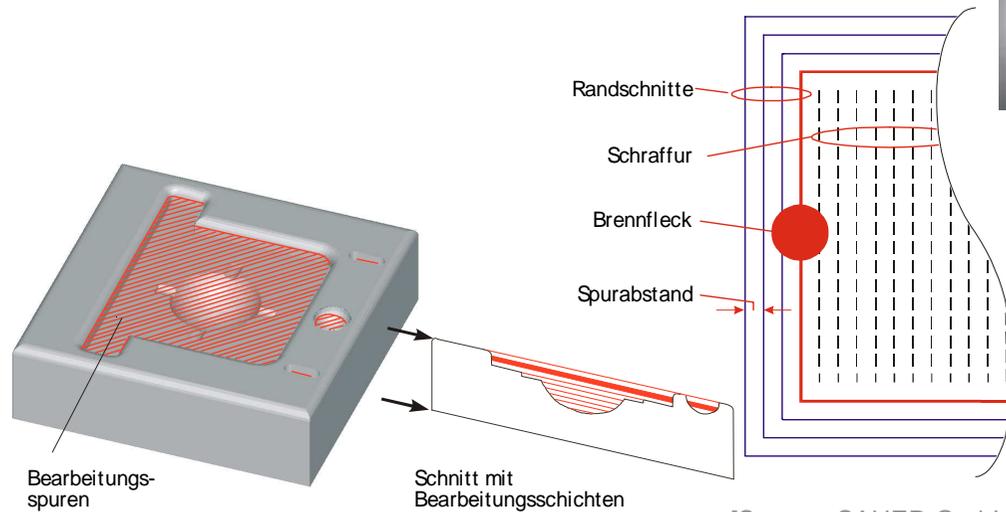
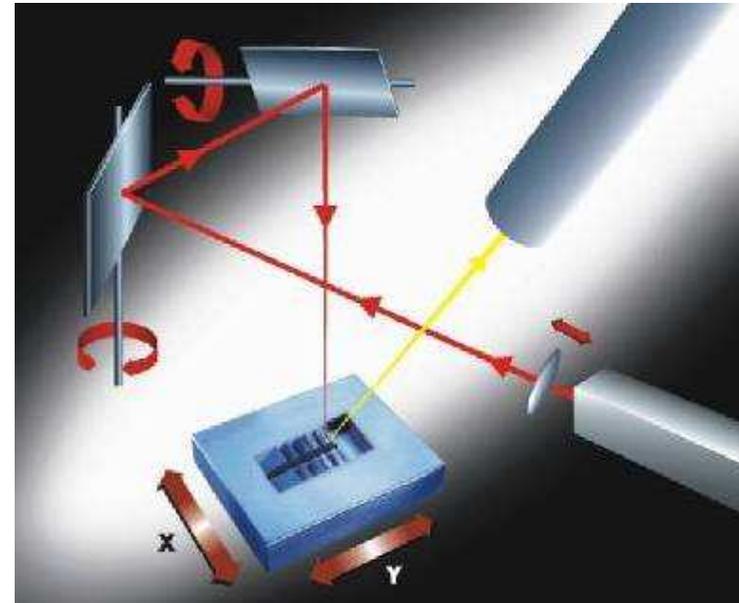
- No interaction of radiation with vapour and melt
- Ablation by vapourisation
- Minimal thermal influence



Process concept for laser micro ablation

Typical parameters

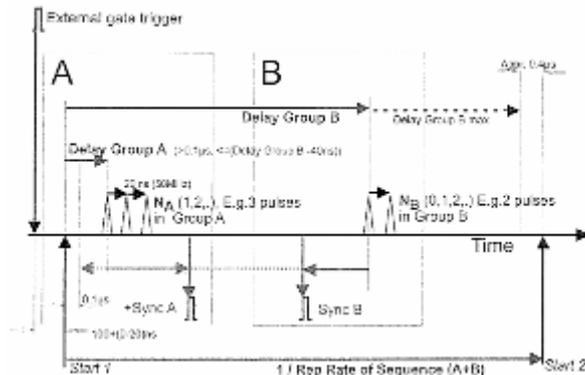
- Focus diameter: 5-40 μm
- Line distance: 5-15 μm
- Layer thickness: 0,1-2 μm



[Source: SAUER GmbH Lasertec]

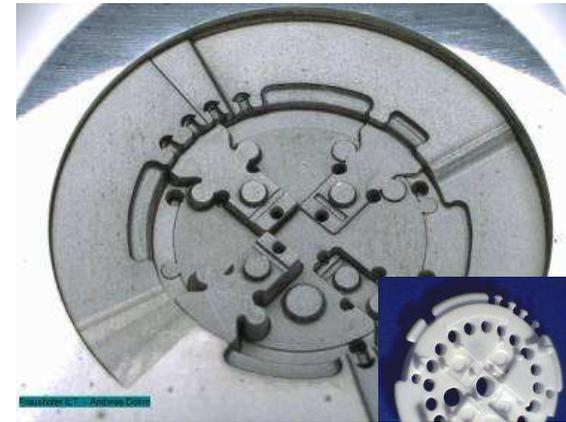
Material ablation with ps-pulse-bursts

- Laser: SuperRapid (Lumera Laser)
- Puls duration $t = 12$ ps
- Repetition rate $f \leq 500$ kHz
- Multi pulse option: yes
- Inter pulse-separation $\Delta t = n \times 20$ ns
- Burst Energy $E_{Bmax} 200 \mu J$

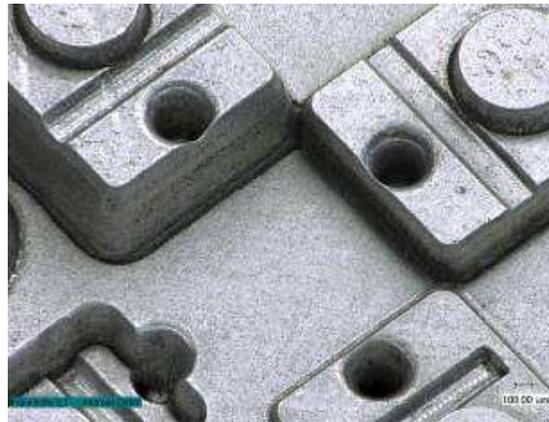


Comparison ns-Laser with ps-Laser

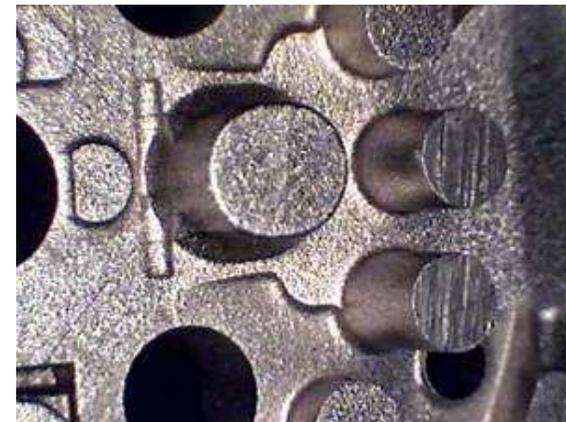
- Time for manufacturing 10 h
- Ablated volume 100 mm³
- Quality of ablation comparable to EDM
- No tools needed



ns-Laser



ps-Laser

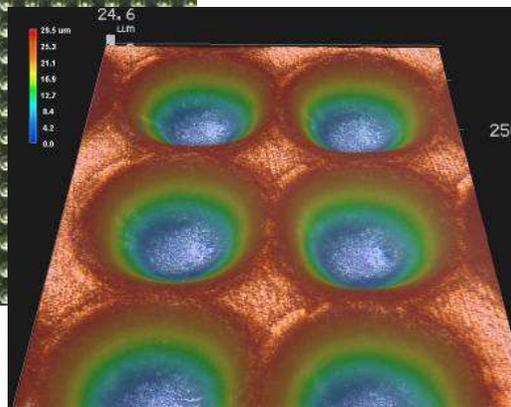


EDM

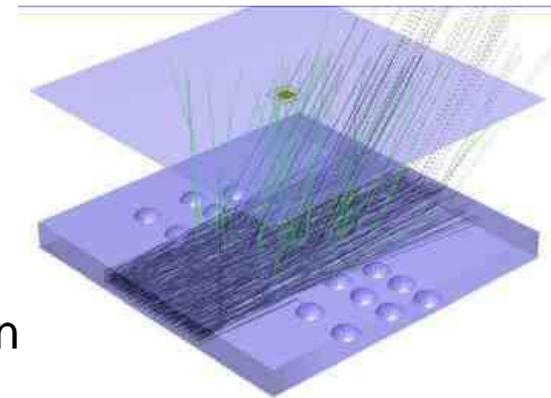
Micro injection moulding of lens arrays in PMMA



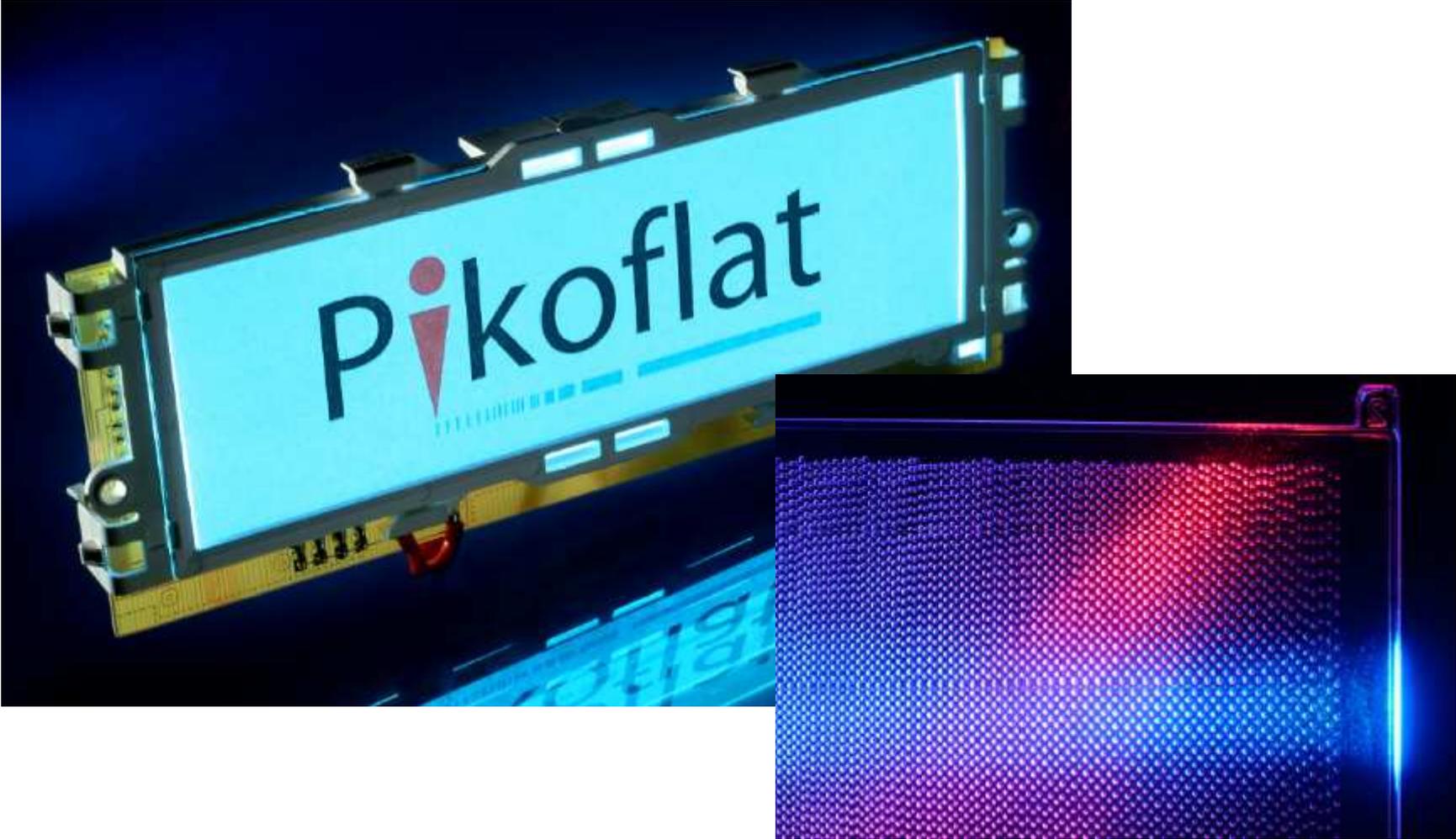
Micro moulding tool for surface structured parts



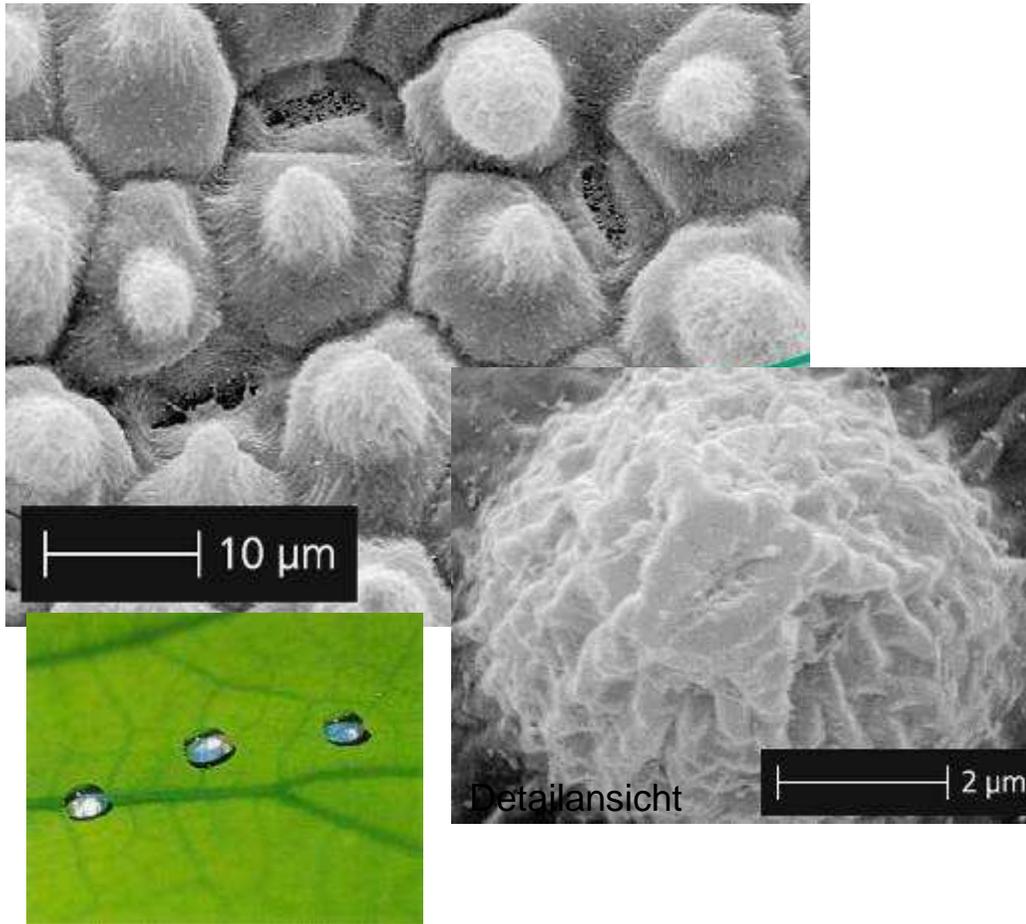
After tool polishing sufficient part quality with surface accuracy better than 100 nm



Light guiding element for LED illumination



Laser structuring for functional surfaces



Hydrophobic surfaces

Natural example:
Lotus leaf

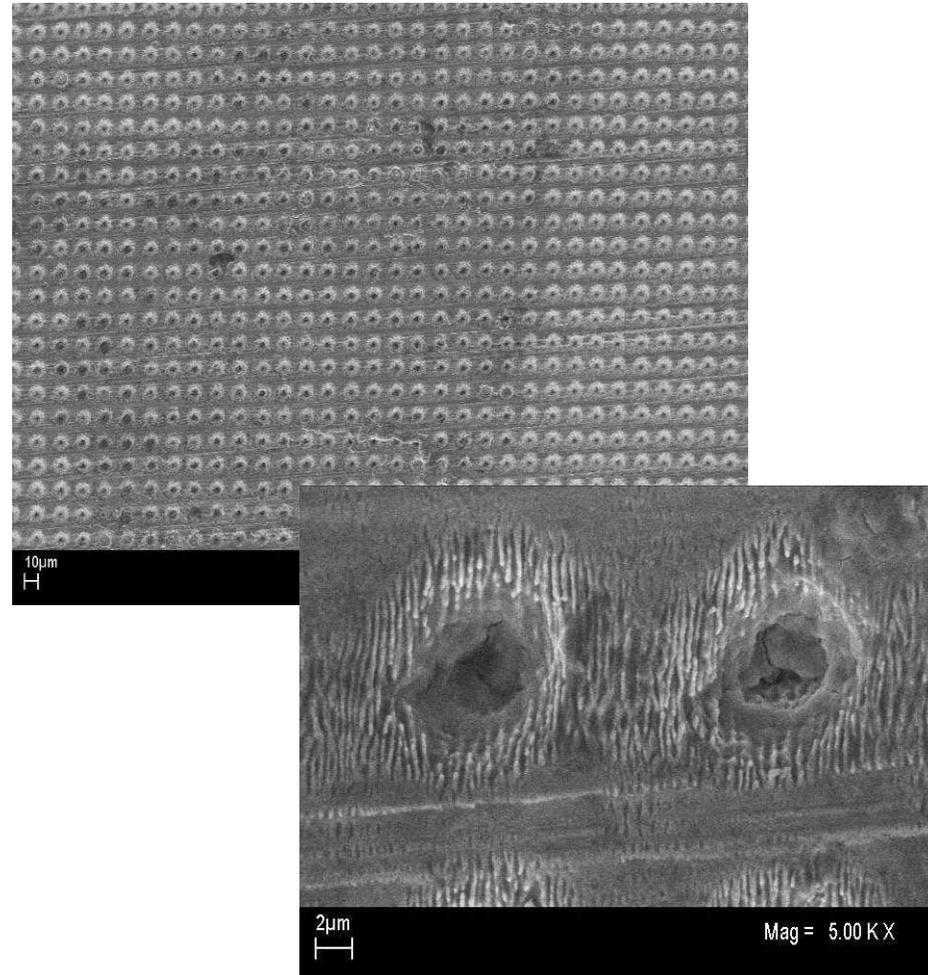
Applications:

- Medical technology
- Bio analytics
- Micro chemistry

Laser structuring of injection moulding tools

Structuring of injection moulding tool with Pikosecond lasers
Lumera Rapid, $\lambda = 355 \text{ nm}$

Generation of multiple structures
Structure size: $10 \mu\text{m}$
Sub structure: $2 \mu\text{m}$
Sub-Sub structure: 100 nm



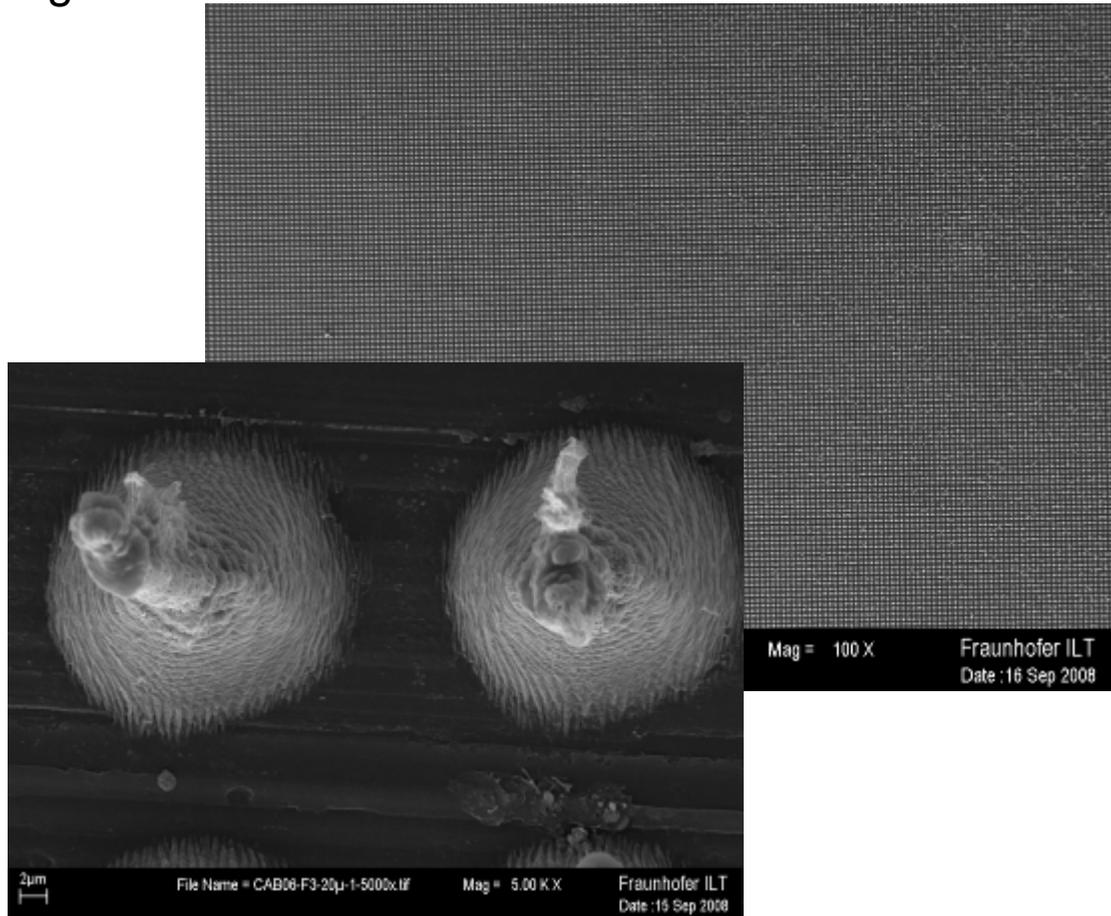
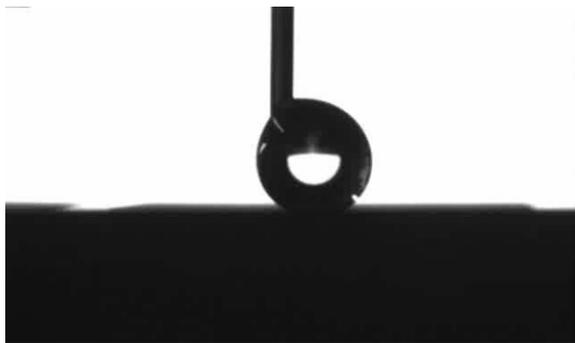
Replication of micro structures surfaces

Replication by injection moulding

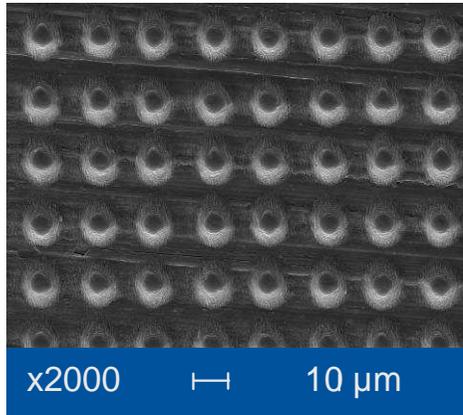
Material: Polypropylen

Contact angle 174°

Minimal Adhesion

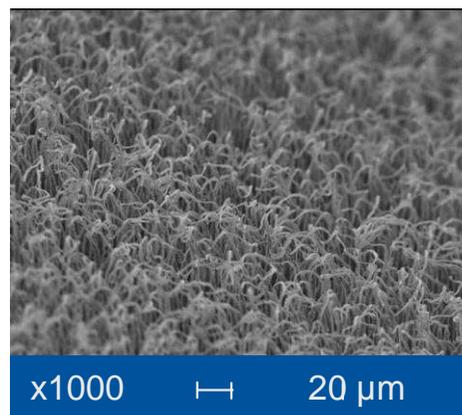
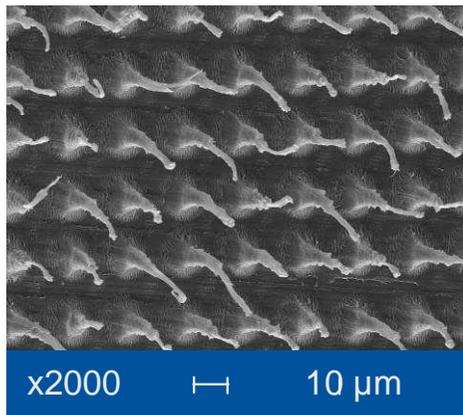
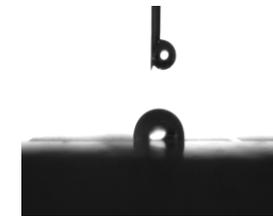


Replication of micro structures surfaces



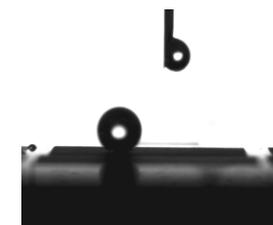
Normal injection moulding

- Micro structures are not filled completely



Vatiorthermal injection moulding

- Micro structures are filled completely
- The structures get stretched during demoulding



Contact angle

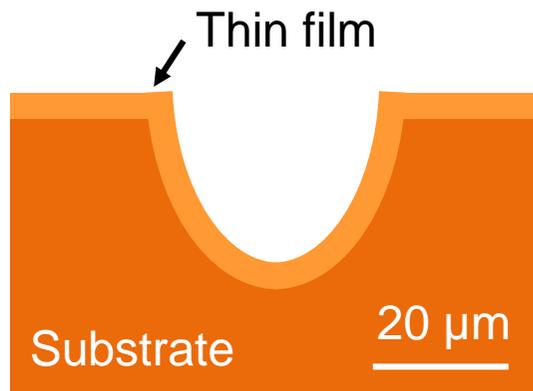


Wear resistant layers

Wear protection of tools due to PVD layers

Two tool concepts are possible

- Deposition of thin film on structured tool (“big” structures (depth: $>10\ \mu\text{m}$))
- Structuring of coated tool (“small” structures (depth: $<5\ \mu\text{m}$))



Coated micro structures

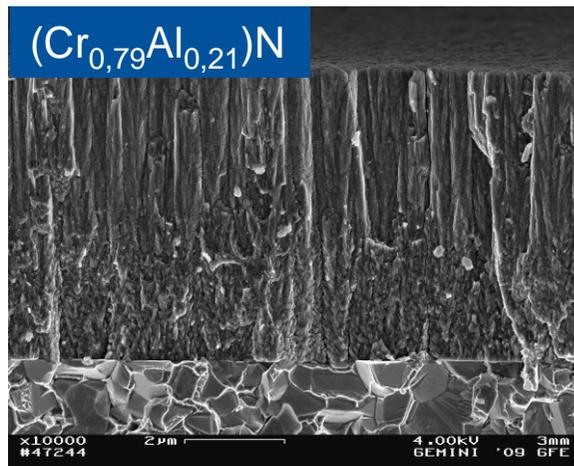


Micro and nano structures in a PVD thin film

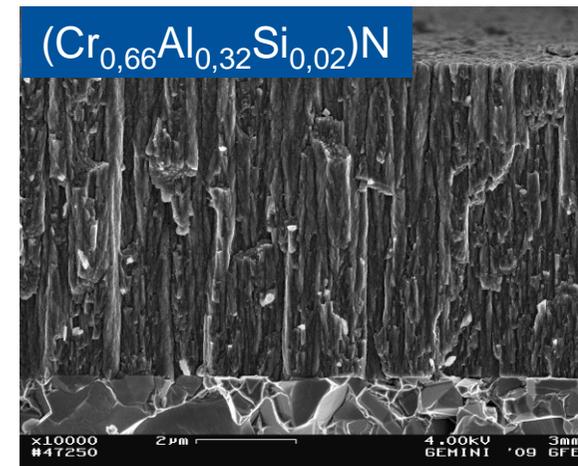
Characterization of the PVD-layers

Characterization regarding:

- Film thickness, morphology (SEM) & chemical composition (at-%) (EDS)
- Hardness & Young's modulus (Fischerscope HM2000; penetration depth 0.5 μm)
- Adhesion – test / Rockwell indentation (VDI 3198)

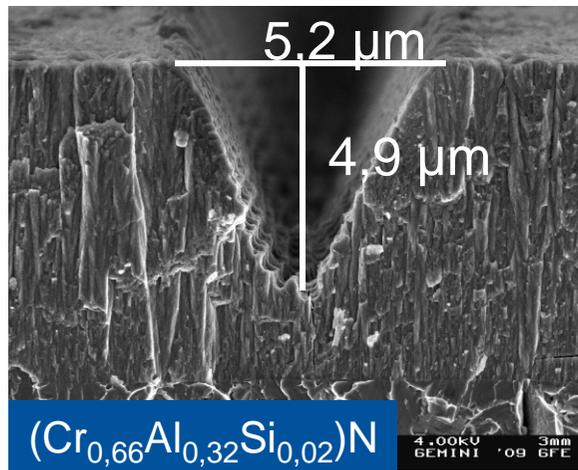
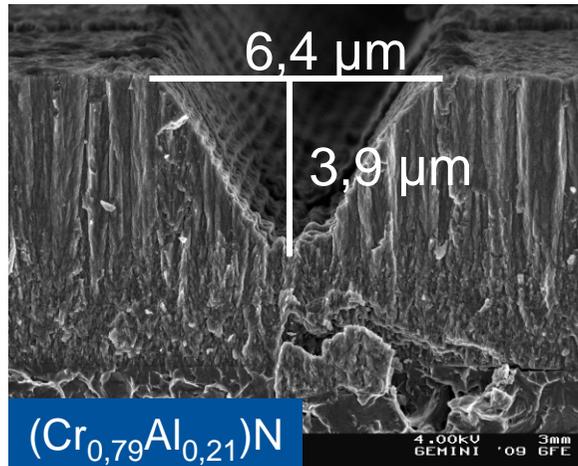


- Columnar film growth
- Thickness: 5.7 μm
- Hardness: 1026 \pm 47 HV
- Young's modulus: 201 \pm 5 GPa
- Adhesion class: 1

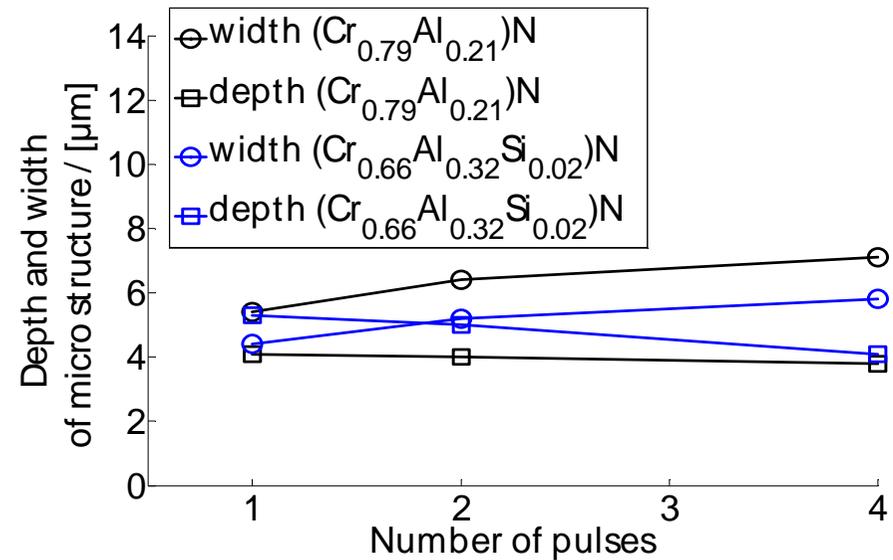


- Columnar film growth
- Thickness : 6.0 μm
- Hardness : 975 \pm 86 HV
- Young's modulus: 175 \pm 8 GPa
- Adhesion class: 1

Micro structuring of the PVD-layers

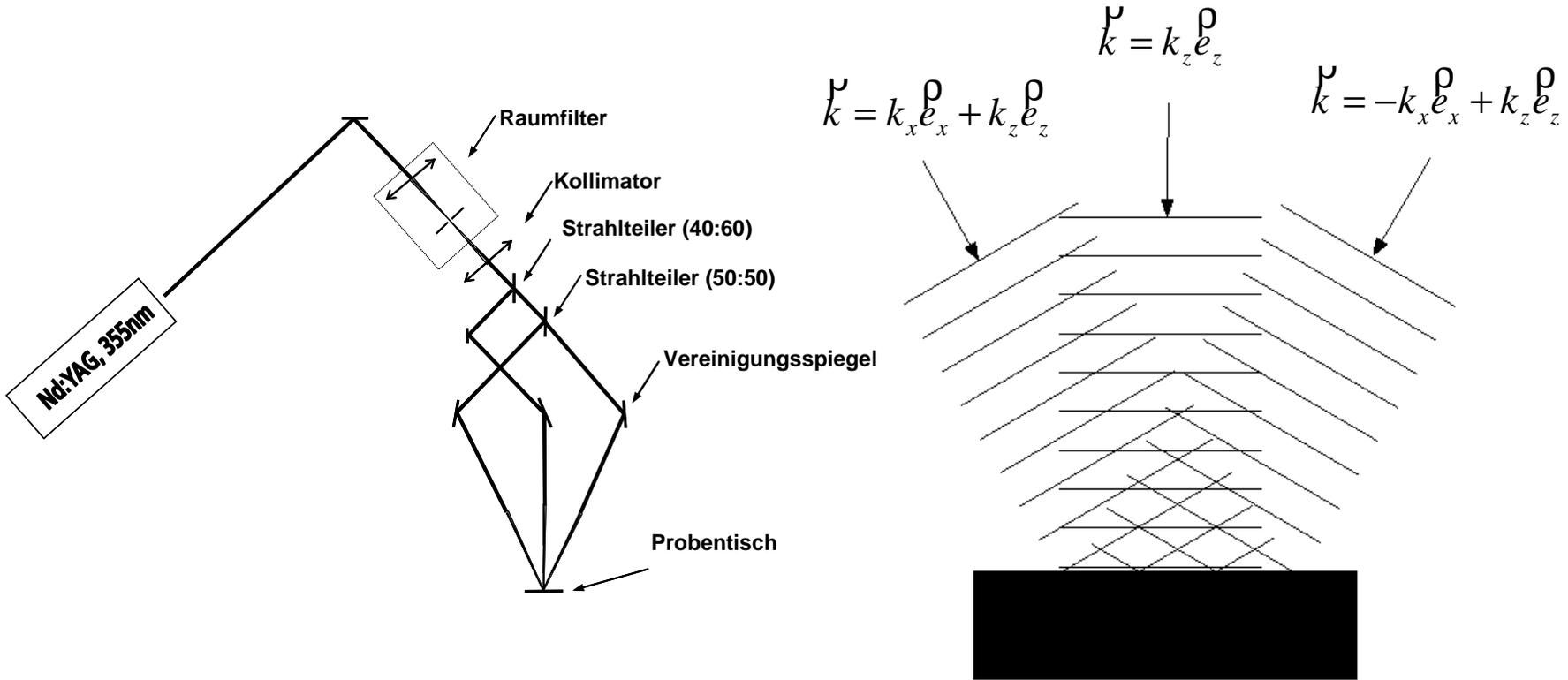


$\lambda = 355 \text{ nm}$
 $E_{\text{burst}} = 0.4 \mu\text{J}$
 double pulses
 $v = 100 \text{ mm/s}$
 10 passes



$\lambda = 355 \text{ nm}$
 $E_{\text{pulse}} = 0.2 \mu\text{J}$
 $E_{\text{burst}} = 0.2, 0.4, 0.8 \mu\text{J}$
 $v = 50, 100, 200 \text{ mm/s}$
 10 passes

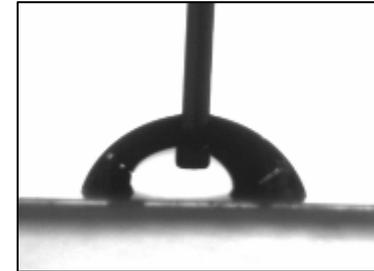
Interference structuring with laser radiation



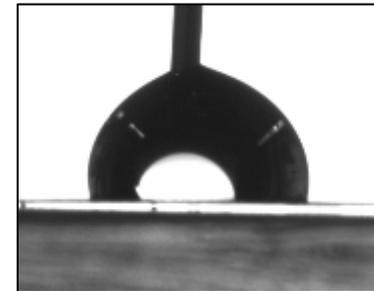
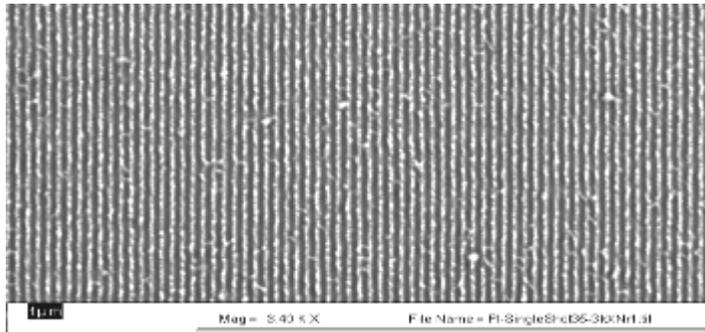
Three beam interference in a plane

Nano structuring for surface functionalisation of polymers

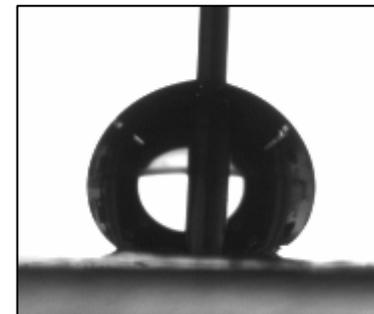
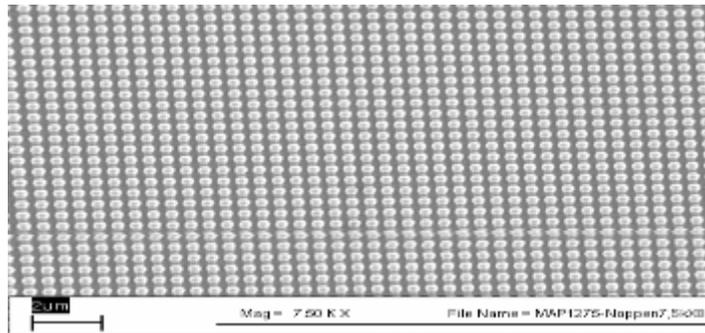
Contact angle of unstructured polyimid $\theta_{H_2O} = 70^\circ$



Polyimid with nano scales
Structure size: 100 nm
 $\theta_{H_2O} = 110^\circ$



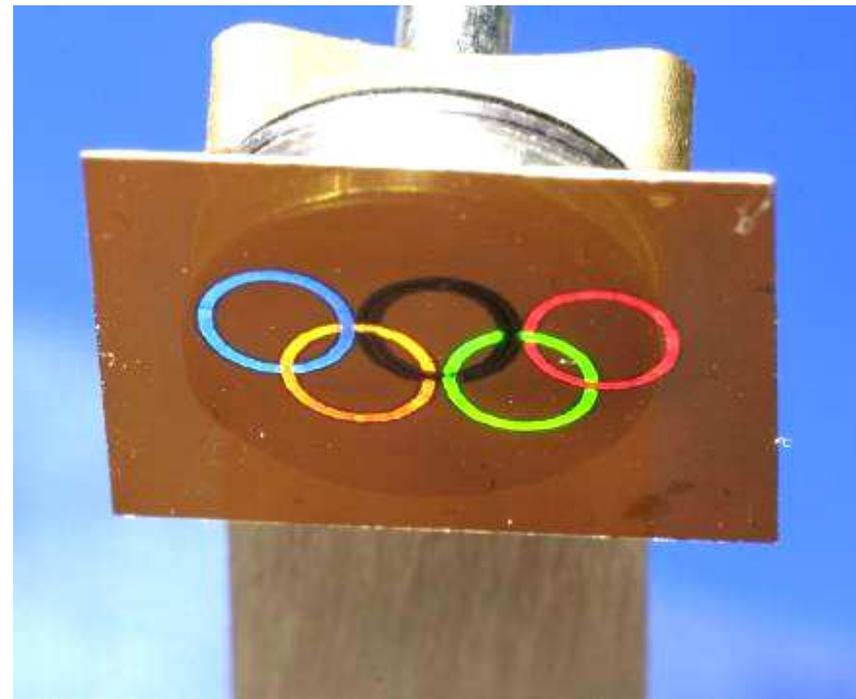
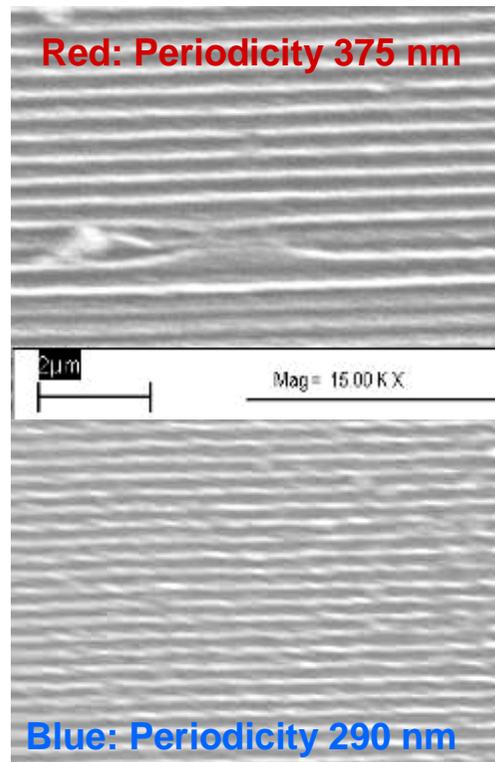
Polyimid mit Nano pits
Structur size: 300 nm
 $\theta_{H_2O} = 145^\circ$



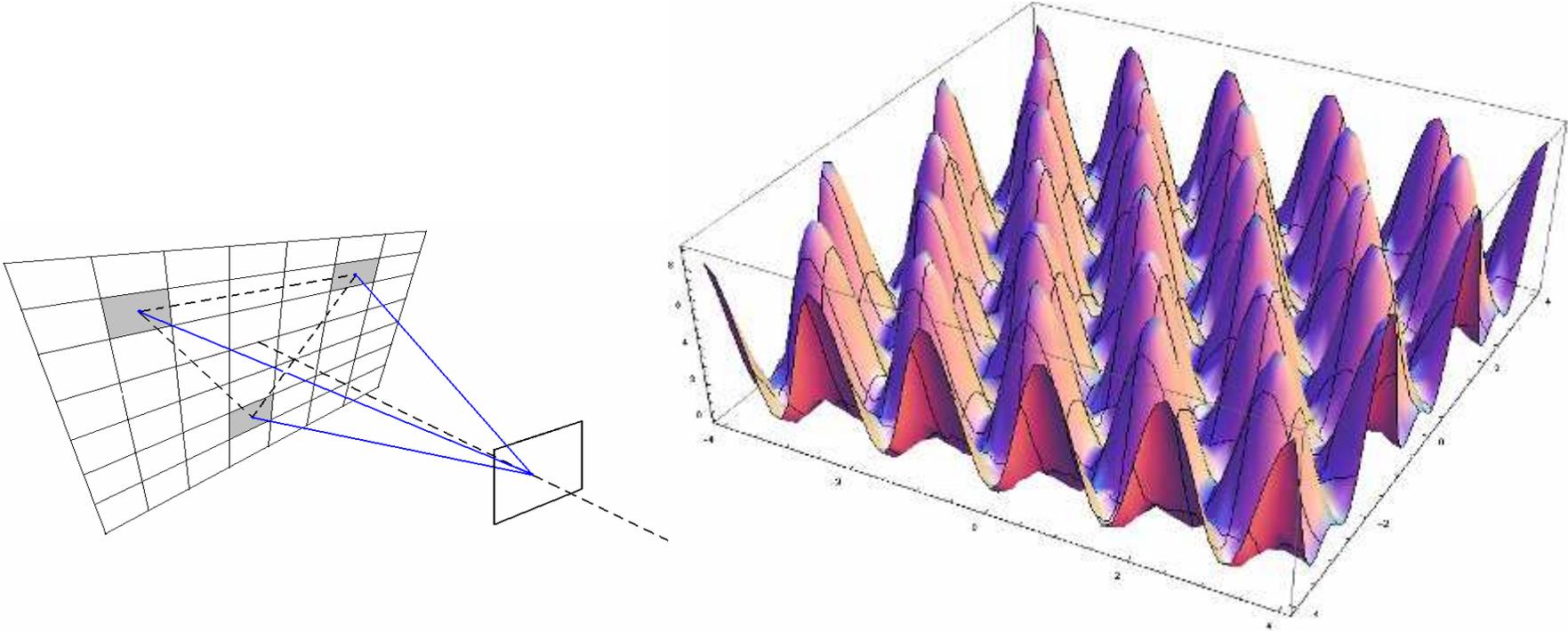
Laser based nano structuring for direct patterning of diffractive structures

Two beam interference

Nd:YAG, 355nm, PI-Folie, $d = 50 \mu\text{m}$



Interference structuring with laser radiation



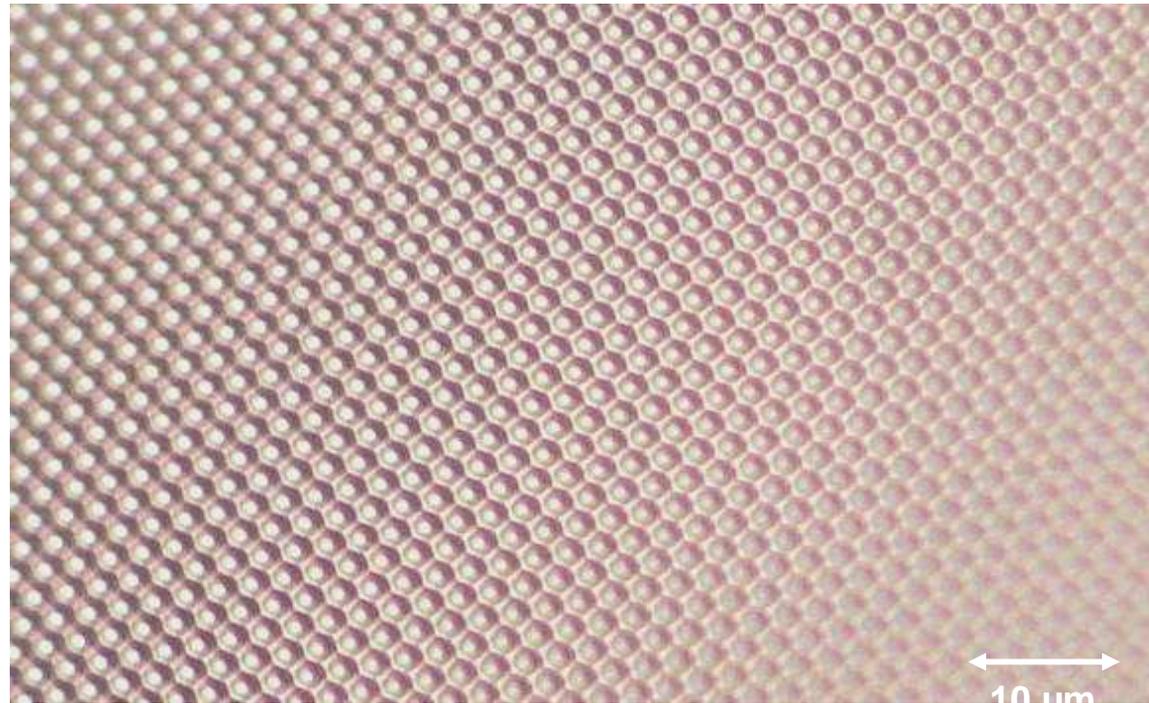
Out of plane three beam interference

Interference structuring with laser radiation

Periodic structure
with negative
illumination
in photoresist

(AR-P 5350)

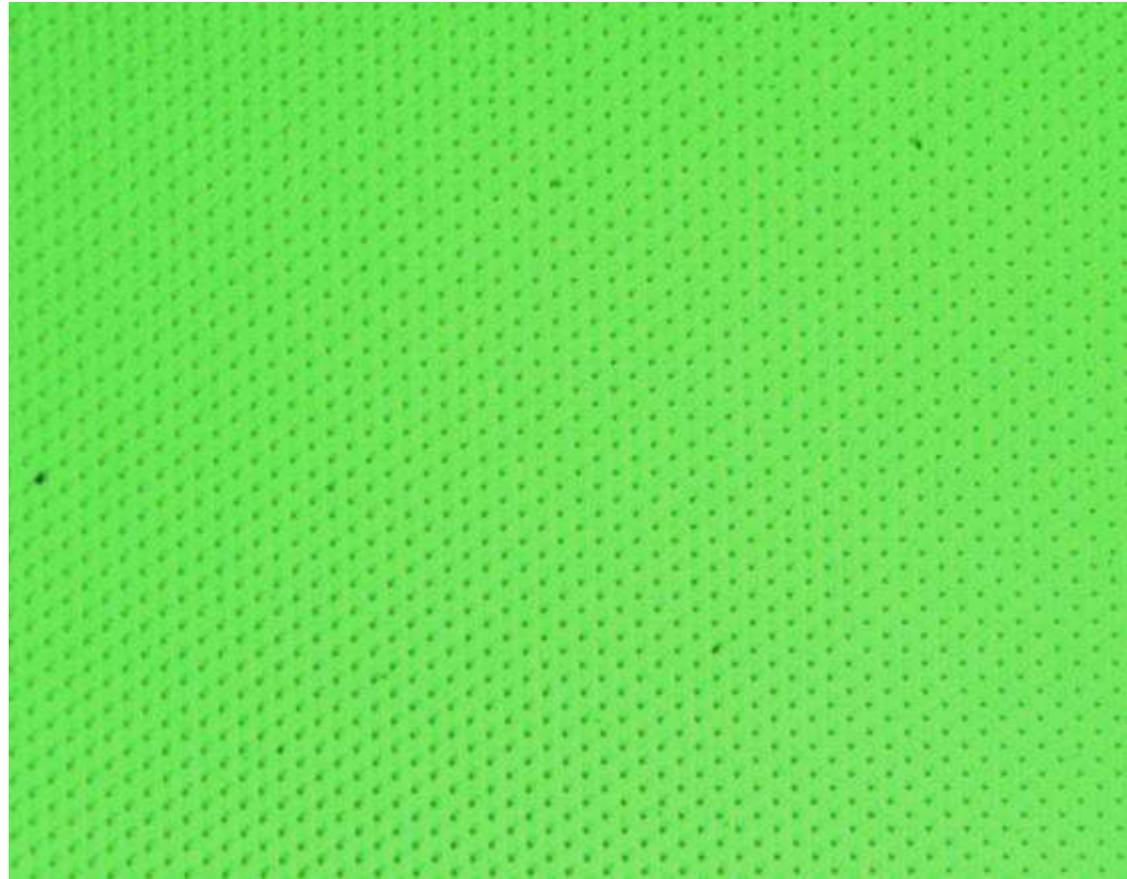
Periodicity $2\mu\text{m}$



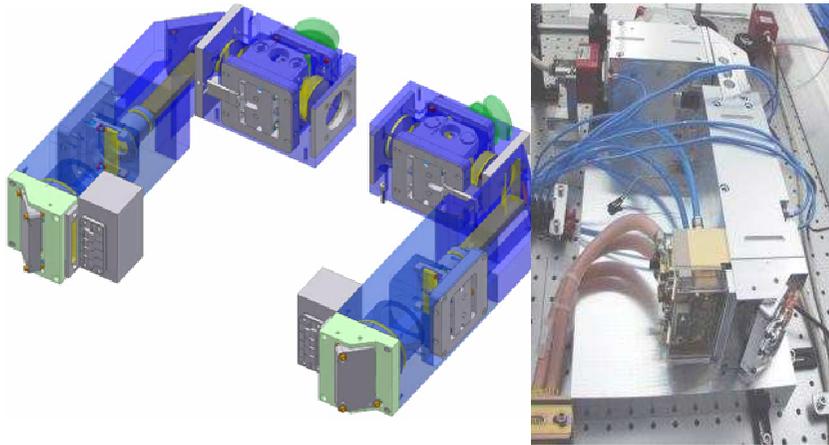
Interference structuring with laser radiation

Hexagonal
pattern
of 1µm holes in
Polyimide-Foil

(100.000 Holes with
one shot)

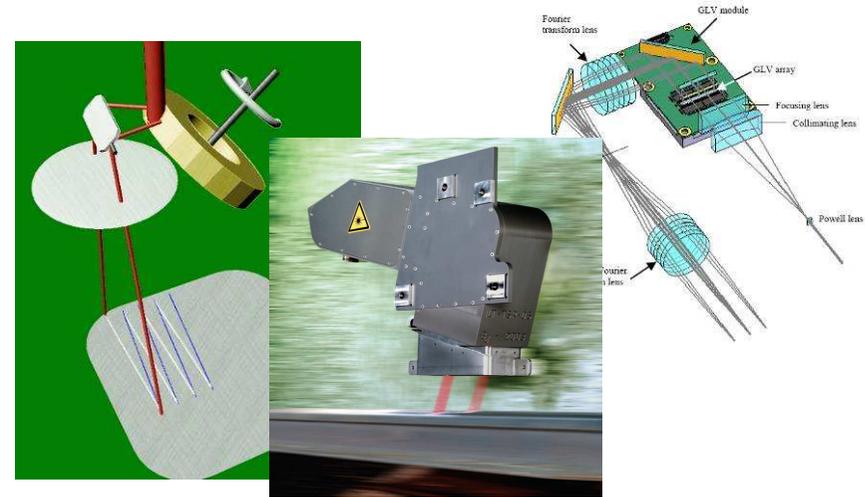


High power ultra short pulsed lasers and fast scanners



Development of high power ultrafast lasers

- 10 ps-Laser with 20 MHz Rep-Rate and $P = 200\text{ W}$
- 500 fs-Laser with 80 MHz Rep-Rate and $P = 300\text{ W}$



Development of process adapted high speed optical systems for ultrafast laser ablation

- High speed scanner systems
- Multiple beam optics for increase of ablation rate

- Founded by German Research Foundation (DFG)



- Cluster of Excellence (CoE)
„Integrative Production Technology for High-Wage Countries“



- CoE sub project C-3.2
"Functional Surfaces via Micro and Nano Scaled Structures"

Thank you for your attention



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